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Claims

- 1. An electrostatic chucking system comprising:
 an electrostatic chuck having an electrode for chucking a semiconductor substrate:
- a power supply section for applying a voltage to said electrode; and a voltage control section for controlling the applied voltage, wherein said voltage control section varies and controls the applied voltage stepwise.
- 2. The electrostatic chucking system according to claim 1, further comprising a temperature sensor for detecting the temperature of the semiconductor substrate held by said electrostatic chuck, wherein a signal output from said temperature sensor is input to said voltage control section to thereby control the applied voltage.
- 3. The electrostatic chucking system according to claim 1, further comprising a warpage sensor for detecting the amount of warpage arising in the semiconductor substrate held by said electrostatic chuck, wherein a signal output from said warpage sensor is input to said voltage control section to thereby control the applied voltage.
- 4. The electrostatic chucking system according to claim 1, further comprising a distance sensor for detecting the distance between said electrostatic chuck and the semiconductor substrate held by said electrostatic chuck, wherein a signal output from the distance sensor is input to said voltage control section to thereby control the applied voltage.
 - 5. The electrostatic chucking system according to claim 1, wherein the control of variation in the applied voltage involves

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- 6. The electrostatic chucking system according to claim 1, wherein the applied voltage is controlled such that a rate at which the temperature change of a semiconductor substrate falls within the range of 10°C/sec. to 150°C/sec.
- 7. A method of manufacturing a semiconductor device comprising a step of treating a semiconductor wafer through use of the electrostatic chucking system according to claim 1.
- 8. An apparatus for manufacturing a semiconductor device, said apparatus comprising the electrostatic chucking system according to claim 1.

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